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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/605,402	09/29/2003	Yueh-Chuan Lee	11141-US-PA	2401	
31561	7590 09/20/2005		EXAMINER		
JIANQ CHYUN INTELLECTUAL PROPERTY OFFICE			GARCIA, JOANNIE A		
7 FLOOR-1,	NO. 100				
ROOSEVELT	ROOSEVELT ROAD, SECTION 2		ART UNIT	PAPER NUMBER	
TAIPEI, 10	TAIPEI, 100			2823	
TAIWAN		DATE MAILED: 09/20/2005			

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
Office Action Comments	10/605,402	LEE ET AL.				
Office Action Summary	Examiner	Art Unit				
	Joannie A. García	2823				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
 A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). 						
Status						
1) Responsive to communication(s) filed on 05 Ju	Responsive to communication(s) filed on 05 July 2005.					
	action is non-final.					
3) Since this application is in condition for allowar	nce except for formal matters, pro	secution as to the merits is				
closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
4) Claim(s) 1-22 is/are pending in the application	4) ☐ Claim(s) 1-22 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration.					
5)⊠ Claim(s) <u>11-22</u> is/are allowed.						
6)⊠ Claim(s) <u>1-4 and 7-10</u> is/are rejected.						
7)⊠ Claim(s) <u>5 and 6</u> is/are objected to.						
	8) Claim(s) are subject to restriction and/or election requirement.					
Application Papers						
9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
•						
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) ■ All b) ■ Some * c) ■ None of:						
1. Certified copies of the priority document		on No				
<u> </u>	2. Certified copies of the priority documents have been received in Application No					
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.						
See the attached detailed Office action for a list of the certified copies not received.						
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 4) Interview Summary (PTO-413) Paper No(s)/Mail Date						
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date		atent Application (PTO-152)				

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Claims 1-10 are objected to because of the following informalities:

In claim 1, line 8, "filing" before "an insulating material into the shallow trench", should be replaced with --filling--.

In claim 8, line 4, "a" before "isolation layer", should be replaced with --an--.

Claim 8 recites the limitation "bottom" in line 5. There is insufficient antecedent basis for this limitation in the claim.

Appropriate correction is required.

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-4, and 8-10, are rejected under 35 U.S.C. 102(b) as being anticipated by Jhabvala (U.S. Patent 4,119,996).

Jhabvala discloses forming a patterned mask layer 52/53 on a substrate 11 (Figure 3, and Column 6, lines 52-58), forming a P-type doped region 15 in the substrate exposed by the mask layer (Figure 4, and Column 6, lines 58-61), wherein a conductivity type of the doped region is different from a conductivity type of an active device 16 subsequently formed on an active area (Figure 7), forming a shallow trench 31 down to the doped region in the substrate after the doped region is formed (Figure 9, and Column 7, lines 22-35), and filling an insulating material 35 into the shallow trench (Figure 10, and Column 7, lines 49-53).

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Jhabvala discloses a substrate 11 having a shallow trench 31 therein (Figure 9, and Column 7, lines 22-35), an isolation layer 35 disposed in the shallow trench (Figure 10, and Column 7, lines 49-53), and a P-type doped region 15 as a channel stop layer disposed directly under a bottom of the shallow trench (Figure 10, and Column 7, lines 49-53), wherein the doped region does not extend to a sidewall of the shallow trench (Figures 9-10), and wherein a conductivity type of the doped region is different from a conductivity type of an active device 16 disposed on an active area (Figure 7).

Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over Jhabvala as applied to claims 1-4, and 8-10, above, and further in view of the following comments.

Jhabvala discloses the claimed invention except for a thickness exceeding 600 angstroms for the patterned mask layer. It would have been obvious to one having ordinary skill in the art at the time the invention was made to determine a suitable thickness to achieve formation of Jhabvala's patterned mask layer 52/53, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable ranges involves only routine skill in the art. *In re Aller*, 105 USPQ 233.

In addition, the selection of a suitable thickness for the patterned mask layer, it's obvious because it is a matter of determining optimum process conditions by routine experimentation with a limited number of species of result effective variables. These claims are prima facie obvious without showing that the claimed ranges achieve unexpected results relative to the prior art range. In re Woodruff, 16 USPQ2d 1935, 1937 (Fed. Cir. 1990). See also In re Huang, 40 USPQ2d 1685, 1688 (Fed. Cir. 1996)(claimed ranges or a result effective variable, which do not

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overlap the prior art ranges, are unpatentable unless they produce a new and unexpected result which is different in kind and not merely in degree from the results of the prior art). See also In re Boesch, 205 USPQ 215 (CCPA) (discovery of optimum value of result effective variable in known process is ordinarily within skill or art) and In re Aller, 105 USPQ 233 (CCPA 1995) (selection of optimum ranges within prior art general conditions is obvious).

Note that the specification contains no disclosure of either the critical nature of the claimed thickness or any unexpected results arising therefrom. Where patentability is said to be based upon particular chosen thicknesses or upon another variable recited in a claim, the Applicant must show that the chosen thicknesses are critical. *In re Woodruf*, 919 F.2d 1575, 1578, 16 USPQ2d 1934, 1936 (Fed. Cir. 1990).

Further, it would have been an obvious matter of design choice bounded by well known manufacturing constraints and ascertainable by routine experimentation and optimization to choose these particular dimensions because applicant has not disclosed that the dimensions are for a particular unobvious purpose, produce an unexpected result, or are otherwise critical, and it appears prima facie that the process would possess utility using another dimension. Indeed, it has been held that mere dimensional limitations are prima facie obvious absent a disclosure that the limitations are for a particular unobvious purpose, produce an unexpected result, or are otherwise critical. See, for example, In re Rose, 220 F.2d 459, 105 USPQ 237 (CCPA 1955); In re Rinehart, 531 F.2d 1048, 189 USPQ 143 (CCPA 1976); Gardner v. TEC Systems, Inc., 725 F.2d 1338, 220 USPQ 777 (Fed. Cir. 1984), cert. denied, 469 U.S. 830, 225 USPQ 232 (1984); In re Dailey, 357 F.2d 669, 149 USPQ 47 (CCPA 1966). See also MPEP 2144.04(IV)(B).

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Claims 5 and 6 would be allowable if rewritten to overcome the objection(s) set forth in this Office action and to include all of the limitations of the base claim and any intervening claims.

Claims 11-22 are allowed.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Joannie García whose telephone number is (571) 272-1861. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith, can be reached on (571) 272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

George Fourson
Primary Examiner
Art Unit 2823

JAG

September 14, 2005

GFourson

Primary Examiner